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FACSIMILE COVER SHEET

To: Examiner Thanh Y. Tran Technology Center 2800	Total Pages Sent: 10 (including cover sheet)
Facsimile Number: 571-273-8300	Transmission Date: February 3, 2006

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

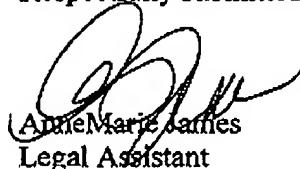
Applicant: Lian, et al. Docket No.: 2004P51100US/
INTECH 3.0-050DIV
Serial No: 10/803,363 Art Unit: 2822
Date Filed: March 17, 2004
Title: Adhesion Layer on SiO₂ and Method

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the following papers are being transmitted by facsimile to the U.S. Patent and Trademark Office at 571-273-8300 on the date shown above:

- Certification of Facsimile Transmission (1 page)
- Amendment After Final Rejection (9 pages)

Respectfully submitted,



Adrienne Marie Barnes
Legal Assistant

Confirmation Respectfully Requested

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Serial No.: 10/803,363

Art Unit: 2822

Filed: March 17, 2004

Examiner: Thanh Y. Tran

Title: Adhesion Layer on SiO₂ and Method

Mail Stop: AF
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL REJECTION

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed December 29, 2005. Prior to the consideration of the application, please further amend the above-referenced application as follows:

2004P51100US/
INTECH3.0-050DIV

Page 1 of 9

Amendment After Final

In the Title:

Please amend the title on page 1 as follows:

Adhesion Layer for Pt on SiO₂ and Method